

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant(s): Annapragada et al.	Group Art Unit: 2813
Application Serial No.: 10/712,326	Examiner: Nguyen, Thanh T
Filed: November 12, 2003)
Title: Minimizing the Loss of Barrier)
Materials During Photoresist)
Stripping)
)

RESPONSE TO FINAL OFFICE ACTION

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir/Madam:

In response to a final office action mailed April 25, 2006 in the above-referenced patent application, please amend the application as follows under the provision of 37 C.F.R. §1.116(a). Allowance of pending claims 1-21 in view of the following amendments and remarks is respectfully requested.

Amendments to the Claims are reflected in the listing of claims which begins on Page 2 of this paper.

Remarks begin on page 9.